

LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S
INFORMATION DISCLOSURE STATEMENTApplicant:
Mun-Pyo HONG, et al.

(Use several sheets if necessary)

Page 1 of 1

Filing Date:
January 12, 2004Group:
Unassigned

REFERENCE DESIGNATION

U.S. PATENT DOCUMENTS

EXAMINERS INITIALS	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPRO.)
	5,969,377	10-1999	Seo, Seong Moh	257	72	
	5,340,761	10-1991	Loh, et al.	437	44	
	5,185,294	11-1991	Lam, et al.	437	193	
	5,313,090	07-1991	Morikawa	257	577	
	6,395,586	02-1999	Huang et al.	438	149	
	6,043,512	09-1997	Adachi	257	66	
	6,218,206	09-1998	Inoue et al.	438	30	
	6,287,899	12-1999	Park et al.	438	149	
	5,677,240	05-1995	Murakami et al.	437	195	
	6,338,988	09-1999	Andry et al.	438	158	
	6,362,028	08-1999	Chen et al.	438	149	
	6,340,610	02-1999	Ahn et al.	438	158	
	5,573,959	05-1995	Kodaira et al.	437	21	
	6,274,412	12-1999	Kydd et al.	438	149	
	5,837,619	11-1995	Adachi et al.	438	795	
	6,159,779	02-1999	Huang et al.	438	158	
	5,734,177	09-1996	Sakamoto	257	49	
	6,017,779	02-1998	Miyasaka	438	149	
	5,289,030	03-1992	Yamazaki et al.	257	410	
	5,403,772	12-1993	Zhang et al.	437	101	

FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
3-238714	10-1991	Japan	HO1B	13/00	<input type="checkbox"/> <input type="checkbox"/>
					<input type="checkbox"/> <input type="checkbox"/>
					<input type="checkbox"/> <input type="checkbox"/>

OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

	Ootani et al. "A 4-mb cmos sram with a pmos thin-film transistor load cell:" IEEE journal of solid-state vol. 25 no. 5 10/90 pg. 1082-1092.
	Jin et al. "High-performance polysyralline si-ge thin-film transistor using Al2O3 gate insulators". IEEE electron device letters vol. 19 no. 12 12/98 Pg. 502-504.
	Lan et al. "An alternative transparent conducting oxide to it ito for the a-si:h TFT-LCD applications" AMLCDs '95 pg. 54-57.

EXAMINER

DATE CONSIDERED

12/9/04

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not conformance and not considered. Include copy of this form with next communication to applicant.